

CrossMark
click for updatesCite this: *Chem. Sci.*, 2016, 7, 4391

Insight into the charge transfer in particulate Ta₃N₅ photoanode with high photoelectrochemical performance†

Zhiliang Wang,^{‡,ab} Yu Qi,^{‡,ab} Chunmei Ding,^a Dayong Fan,^{ab} Guiji Liu,^{ab} Yongle Zhao^{ab} and Can Li^{*a}

Charge separation is one of the most critical factors for generating solar fuels *via* photoelectrochemical water splitting, but it is still not well understood. This work reveals the fundamental role of charge transfer in photoanodes for achieving high charge separation efficiency. Specifically, we fabricated a particulate Ta₃N₅ photoanode by a bottom-up method. By improving the charge separation with refined necking treatment, the photocurrent is increased by two orders of magnitude. The charge separation efficiency (η_{sep}) is analyzed by dividing it into charge generation efficiency (Φ_{gene}) and transportation efficiency (Φ_{trans}). Necking treatment is found to substantially improve the electron transfer. Transient photovoltage (TPV) measurements based on the Dember effect is used to confirm the benefit of necking treatment in improving the charge transportation. The superior electron transfer in the necked-Ta₃N₅ electrode is further evidenced by the facile electron exchange reaction with the ferri/ferrocyanide redox couple. Moreover, cobalt phosphate is found to promote both charge separation and surface reaction, resulting in a photocurrent of 6.1 mA cm⁻² at 1.23 V vs. RHE, which is the highest response for a particulate photoanode.

Received 18th January 2016

Accepted 16th March 2016

DOI: 10.1039/c6sc00245e

www.rsc.org/chemicalscience

Introduction

Photo-induced water splitting paves a promising way for the production of renewable solar fuels by converting solar energy to hydrogen directly. To achieve this conversion process, photocatalysis (PC) and photoelectrocatalysis (PEC) are viable technological choices.^{1–4} Many kinds of materials have shown photoresponse in PC but failed in PEC due to the issue of electrode fabrication.^{2,5,6}

In PC, an efficient charge separation in particles can usually lead to fast reaction at the semiconductor/liquid interface with the assistance of a suitable cocatalyst.⁷ In PEC, however, photogenerated electrons must transfer through the film and be collected by the substrate to match the surface reaction. Thus, the charge transportation in the films also plays a fundamental role in the whole PEC process,⁸ and the interfaces of particle–particle (PP) and particle–substrate (PS) are critically important for charge transportation. To ensure

good connections at these interfaces, semiconductor is usually epitaxially grown on a conductive layer *in situ* by, for instance, hydrothermal,⁹ chemical bath,¹⁰ and vapour deposition methods.^{11,12} Electrodes of low-dimensional structure^{13,14} or host–guest structure^{15,16} are intentionally designed to improve the charge transportation efficiency in the electrode so as to decrease the electron–hole recombination. However, most previous researches focus on charge transfer in the semiconductor particles since it determines the generation of separated electron–hole pairs,^{17–19} and little attention has been paid on clarifying the charge transfer process in the film, which also plays a determinable role during the photoelectrochemical reaction.

Transient photovoltage (TPV) can provide direct insight into the charge transfer process through the electrode. Upon illumination, Dember photovoltage is generated²⁰ which stems from the diffusion difference of photogenerated electrons and holes. Typically, the gradient distributed light in the film excites photogenerated electron–hole pairs in gradient concentration^{21,22} which will cause them to diffuse from a high concentration region (surface, high light intensity) to the low concentration region (bulk, low light intensity) at different velocities. Then the electron–hole pairs drift apart and electric field builds up; the decay process of the photovoltage can reveal the charge transfer process in the film.

Cyclic voltammetry (CV) in the dark can also reveal the electron transfer in electrodes.²³ For the cathodic reaction,

^aState Key Laboratory of Catalysis, Dalian Institute of Chemical Physics, Chinese Academy of Sciences, Dalian National Laboratory for Clean Energy, The Collaborative Innovation Center of Chemistry for Energy Materials (iChEM), Zhongshan Road 457, Dalian, 116023, China. E-mail: canli@dicp.ac.cn

^bUniversity of the Chinese Academy of Sciences, Beijing, 100049, China

† Electronic supplementary information (ESI) available. See DOI: 10.1039/c6sc00245e

‡ These authors contribute equally to this work.



electrons must transfer through the films before exchanging with an efficient redox couple, *e.g.* $\text{Fe}(\text{CN})_6^{3-}/\text{Fe}(\text{CN})_6^{4-}$. The magnitude of the cathodic current and potential of the reduction peak can reveal the electron transportation in the film. In addition, a particulate electrode with well-connected film can result in porous structure which provides a large electrochemical surface area for reaction. This area is proportional to the capacitance of the Helmholtz layer which can be determined from CV²⁴ and so we can evaluate the charge transportation in the film by an electrochemical method.

Suitable materials and fabrication methods of the electrodes are important for us to pinpoint the issue of charge transportation. In terms of materials, semiconductors with long free paths are the best candidates because it permits us to focus on the charge transfer at the PP interfaces regardless of the charge diffusion in the semiconductor crystals. Ta_3N_5 is reported to have a diffusion length of $\sim 10^3$ nm,²⁵ indicating a long life time of photogenerated charges. Moreover, Ta_3N_5 has demonstrated an outstanding photocatalytic oxygen evolution activity,²⁶ indicating an effective charge separation in Ta_3N_5 crystals. Also, the excellent light harvesting ability of Ta_3N_5 makes it an appealing material for photoelectrochemical water splitting with a potential solar energy conversion efficiency of 15% under AM 1.5 G sunlight.²⁷ For the fabrication of the electrode, a bottom-up method, that is by depositing as-prepared semiconductor particles on the conductive substrate to form a particulate electrode, can make it more facial so as to regulate the charge transfer at the PP and PS interfaces without influencing the intrinsic properties of the semiconductor such as light absorption, carrier concentration *etc.* Electrophoretic deposition (EPD) method is an alternative choice. A wide range of semiconductors can be fabricated into electrodes with controllable thickness by EPD, such as Fe_2O_3 ,²⁸ BiVO_4 ,²⁹ Ta_3N_5 ,³⁰ TaON ,^{31,32} while post-necking treatment has been found to be powerful in improving the PEC response.^{30–34} Some explanation to the possible function of necking treatment has been proposed,³¹ but more stringent evidences are required to identify the effects of this modification.

Herein, we take Ta_3N_5 as a demonstration to show the influence of charge transportation on the PEC performance of a particulate Ta_3N_5 electrode. By optimizing the substrate, precursor concentration, temperature of necking treatment and cocatalyst loading, we have achieved the highest photocurrent for electrodes fabricated by EPD. The TPV based on Demer photovoltage and CV measurements are used to clarify the critical effect of necking treatment on charge transfer at the interfaces of particle–particle and particle–substrate.

Experimental

Ta_3N_5 powder synthesis

Ta_2O_5 powder (Amresco Chemical, $\geq 99.99\%$) was immersed in water, then it was dried and annealed in air at 800 °C for 2 h, prior to being nitrided in ammonia flow (250 sccm) at 950 °C for 15 h.

Ta_3N_5 electrode fabrication

The as-synthesized Ta_3N_5 powder (50 mg) was dispersed into 50 mL acetone (Kemeol, $\geq 99.5\%$) under ultrasonic treatment for 10 min. Then 20 mg iodine was dissolved into the suspension to make it suitable for EPD. Ti foil (1 cm $\times$ 2 cm) was used as substrate after washing in 1 M HF aqueous, pure water and anhydrous ethanol. A piece of fluorine-doped tin oxide (FTO, Nippon Glass Sheet) glass (2 cm $\times$ 3 cm) is used as the counter electrode with the conductive layer facing towards the Ti foil at a distance of 1 cm. The Ta_3N_5 crystals were deposited to the Ti foil at a bias of 20 V for 1 min.

Necking treatment

20 mM TaCl_5 (Alfa Aesar, $\geq 99.99\%$) was dissolved into anhydrous methanol (Sinopharm Chemical Reagent, $\geq 99.5\%$) and 10 μL TaCl_5 solution was then dropped onto the raw Ta_3N_5 electrode (denoted as raw- Ta_3N_5 , area of 1–1.3 cm²) five times (50 μL in total) to form the TaCl_5 treated Ta_3N_5 electrode (denoted as TaCl_5 - Ta_3N_5 electrode) based on ref. 40. Then the TaCl_5 - Ta_3N_5 electrode was calcined at 600 °C (5 °C min^{−1}) for 60 min under NH_3 flow (100 sccm), and the as-prepared electrode is denoted as necked- Ta_3N_5 . For comparison, the raw- Ta_3N_5 electrode was also heated in the same way without TaCl_5 solution (denoted as heated- Ta_3N_5).

Cobalt phosphate deposition

5 mM $\text{Co}(\text{NO}_3)_2$ (Sinopharm Chemical Reagent, $\geq 99.0\%$) was dissolved into 0.5 M NaPi buffer solution (pH 6.8). Then CoPi was electrochemically deposited onto the Ta_3N_5 electrode under simulated light (AM 1.5 G, 100 mW cm^{−2}) illumination at a current density of 10 $\mu\text{A cm}^{-2}$.

Characterization

The absorption spectra from 350 to 800 nm were taken on Cary 5000 UV-VIS-NIR spectrophotometer (JASCO) equipped with an integrated sphere. X-Ray diffraction (XRD) patterns were recorded on Rigaku D/Max-2500/PC powder diffractometer operating at 40 kV and 200 mA with Cu-K α radiation ($\lambda = 0.154$ nm) at a scanning rate of 5° min^{−1}. The morphology of the electrodes was imaged by a Quanta 200 FEG scanning electron microscope (SEM). High-resolution transmission electron microscopy (HRTEM) images were obtained on Tecnai G2 F30 S-Twin (FEI Company) with an accelerating voltage of 300 kV. X-Ray photoelectron spectroscopy (XPS) was recorded on VG ESCALAB MK2 spectrometer with monochromatic Al-K α radiation (12.0 kV, 240 W). All the bonding energies were corrected with reference to the C 1s (284.8 eV) signal.

Transient photovoltage measurement

The transient photovoltage (TPV) was measured with a pulsed laser (355 nm, 5 ns) using a Ta_3N_5 device (see ESI for details†). The average power was 122 mW unless otherwise stated. The signals were read from an oscilloscope (Tektronix TDS 3012C).



(Photo)electrochemistry measurement

Cyclic voltammetry was measured without illumination in an electrolyte of NaOH (1 M) or NaOH (1 M)–K₃Fe(CN)₆ (0.25 M) aqueous solution at a scan rate of 100 mV s^{−1} in the range of −1.4 to 0.4 V vs. SCE. For the electrochemical area measurement, the scan rate was varied from 20 to 500 mV s^{−1} in the range of −0.1 to 0.2 V vs. SCE in 1 M NaOH aqueous solution.

The photocurrent was recorded under simulated light (AM 1.5 G, 100 mW cm^{−2}) at a scan rate of 50 mV s^{−1} from −0.8 V to 0.6 V vs. SCE in 1 M NaOH aqueous solution (pH 13.6).

The incident photon-to-current conversion efficiency (IPCE) was measured under monochromatic light irradiation provided by a tungsten lamp equipped with a monochromator (CROWNTECH, QEM24-D 1/4 m Double).

Faradaic efficiency was tested by recording the photocurrent and the generated O₂ simultaneously. The O₂ evolution was evaluated by gas chromatography (GC, Agilent 7890a GC) with a 5 Å molecular sieve column. Argon carrier gas with a velocity of 10.0 mL min^{−1} was used to purge the working electrode compartment to carry the evolved gases to GC for analysis. The quantity and retention time of the gases were calibrated with a series of standard gas samples.

All the (photo)electrochemical tests were conducted on an Ivium potentiostat/galvanostat in a three-electrode system with a quartz window. A piece of platinum foil (2 cm × 2 cm) was used as counter electrode and saturated calomel electrode (SCE, 0.241 V vs. RHE) used as the reference electrode. The potential was converted to the reversible hydrogen electrode (RHE) scale by the Nernst equation as below:

$$E(\text{RHE}) = E(\text{SCE}) + 0.059\text{pH} + 0.241 \quad (1)$$

Results and discussion

The morphology of the electrodes was first characterized by SEM. The SEM image of a cross-section view shows that the as-prepared electrode has a thickness of 5–7 μm (Fig. S1†). Top-view images show that the surface of porous raw Ta₃N₅ (Fig. 1a) is covered with an amorphous layer after treating with TaCl₅ solution (Fig. 1b). The following heat treatment seems to retrieve the smooth surface of Ta₃N₅ but boundaries between particles become less obvious compared to those on raw-Ta₃N₅ electrode (Fig. 1c). The HRTEM image confirms the existence of a 1–5 nm amorphous layer (Fig. 1d). This amorphous tantalum species may bridge the adjacent Ta₃N₅ particles. The XRD patterns (Fig. S2†) show no change of the Ta₃N₅ crystals with necking treatment, however, the surface change was revealed in XPS spectra (Fig. 1e). There is no prominent difference between raw-Ta₃N₅ and heated-Ta₃N₅ electrodes but for the TaCl₅–Ta₃N₅ electrode, another peak at 28.1 eV was observed, in agreement with the reported Ta 4f_{5/2} signal in tantalum oxide.^{35,36} It is inferred that the amorphous layer in Fig. 1b may be tantalum oxide. Since it was covered on the raw-Ta₃N₅ electrode, the intensity of O 1s (530.7 eV) became stronger, and the intensity of Ta 4f_{7/2} (24.6 eV) became weaker after treating with TaCl₅

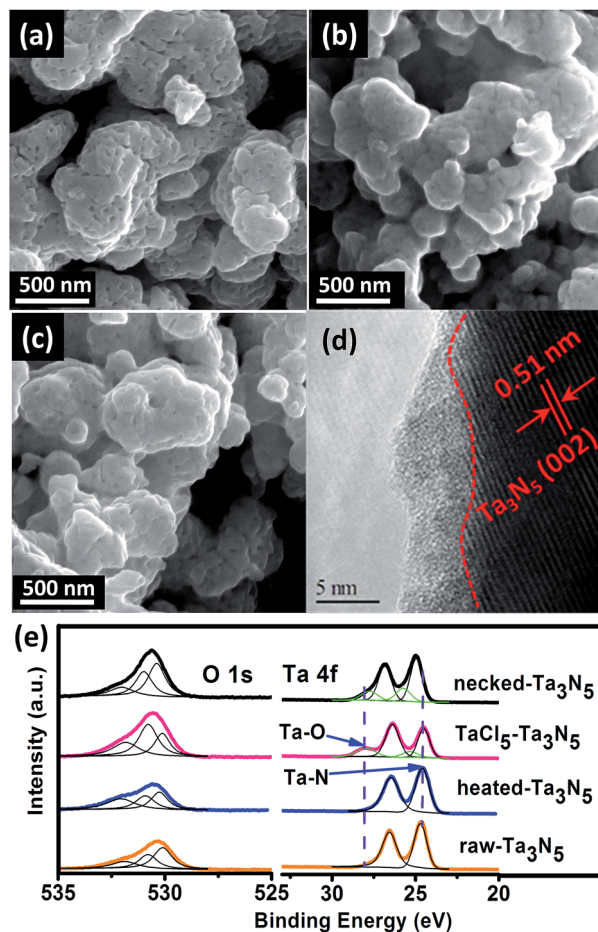


Fig. 1 SEM images of (a) raw-Ta₃N₅ electrode, (b) TaCl₅–Ta₃N₅ electrode, and (c) necked-Ta₃N₅ electrode. (d) HRTEM image of necked-Ta₃N₅ electrode. (e) XPS spectra of O 1s and Ta 4f for raw-Ta₃N₅ (orange), heated-Ta₃N₅ (blue), TaCl₅–Ta₃N₅ (pink) and necked-Ta₃N₅ (black) electrodes.

solution, indicating the screening effect of the amorphous tantalum oxide. It is also inferred that Ta 4f_{7/2} at 24.6 eV arises from Ta–N bonds. After necking treatment, the intensity of O 1s (530.7 eV) ascribed to surface absorbed oxygen species is prominently decreased compared to the TaCl₅–Ta₃N₅ electrode, with Ta 4f_{5/2} ascribed to Ta–O shifted from 28.0 to 27.6 eV, and Ta 4f_{7/2} ascribed to Ta–N bond shifted from 24.6 to 25.0 eV for the necked-Ta₃N₅ electrode. It is suggested that a nitrogen-doped tantalum layer has been formed. Because the Ta–N bond is more covalent than the Ta–O bond, nitrogen doping of tantalum oxide during necking treatment will shift the binding energy of Ta 4f to lower energy.^{36–38}

Despite the small changes of the morphology of Ta₃N₅ particles, the PEC performance shows a substantial difference with necking treatment (Fig. 2a). The raw-Ta₃N₅ electrode exhibits notoriously low photoresponse, and so does the TaCl₅ treated electrode. However, after necking treatment, the photocurrent of the necked-Ta₃N₅ electrode increases to 1.56 mA cm^{−2} from 9 μA cm^{−2}. For the necking treatment, the TaCl₅ concentration and post-heating temperature have great influence on the photoresponse of the necked-Ta₃N₅ electrode

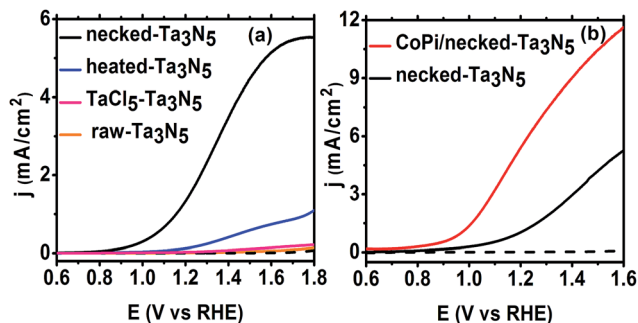


Fig. 2 Current-potential (j - E) curves of (a) raw-Ta₃N₅ (orange), TaCl₅-Ta₃N₅ (pink), heated-Ta₃N₅ (blue), necked-Ta₃N₅ (black) and (b) CoPi/necked-Ta₃N₅ (red) electrode. Electrolyte: 1 M NaOH aqueous solution. Illumination: 100 mW cm⁻², AM 1.5 G.

(Fig. S3†). The optimized TaCl₅ concentration is 15–20 mM (concentration at 20 mM gives the best repeatability) and the best post-heating temperature is 600 °C for the refined necking treatment. At high temperature, the particles will have strong connection with each other at the PP and PS interfaces. However, NH₃ has strong capability of reduction at high temperature, and can damage the normally used FTO substrate.^{28,31} Some metal based candidates were chosen and Ti foil gave the best result (Fig. S4†). The benefit of calcination is also confirmed by the improved photoresponse of heated-Ta₃N₅ compared to the raw-Ta₃N₅ electrode. Further cocatalyst loading, *e.g.* CoPi,³⁹ on necked-Ta₃N₅ electrode efficiently accelerates the water oxidation to an optimized current of 6.1 mA cm⁻² at 1.23 V *vs.* RHE (Fig. 2b), which is higher than most reported results fabricated by the EPD method.^{30,31,40,41} In Fig. 3, IPCE action spectra show the quantum efficiency at different irradiation wavelengths, which are in agreement with the absorption of Ta₃N₅. The raw-Ta₃N₅ electrode shows very low IPCE, but after the refined necking treatment, it dramatically increases to more than 20%. Also, the IPCE is much higher by loading CoPi or increasing the bias to accelerate the consumption of photogenerated charges.

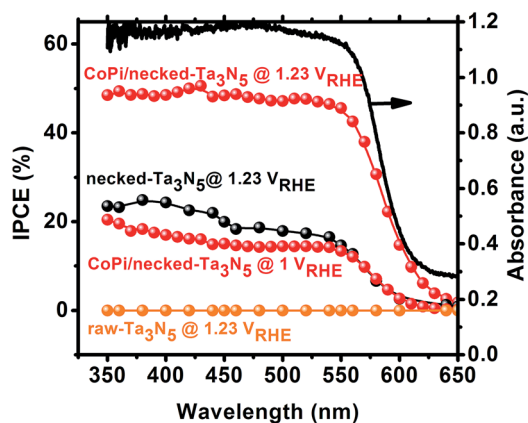


Fig. 3 IPCE of raw-Ta₃N₅ (orange), necked-Ta₃N₅ (black) and CoPi/necked-Ta₃N₅ (red) electrodes. The absorption spectrum (black solid curve) for raw-Ta₃N₅ is presented for comparison.

The refined necking treatment plays a key role in boosting the photoanodic performance of the particulate Ta₃N₅ electrode and it is also essential for the cocatalyst functioning Ta₃N₅ photoanode. Thus we endeavour to pinpoint the exact role of necking treatment by analysing the reaction at the semiconductor/liquid interface and charge transfer at PP and PS interfaces on the particulate Ta₃N₅ electrode.

For an electrode made from powder, necking treatment may have an influence on both the intrinsic property of Ta₃N₅ particles and the connection among particles. In order to elucidate the possible change of Ta₃N₅ crystals, the absorption spectra and photocatalytic activity (see ESI for details†) were measured. The absorption spectrum of Ta₃N₅ shows little change after necking treatment (Fig. S5a†), indicating that the necking treatment does not influence the intrinsic light harvest in Ta₃N₅. From the absorption spectra, the marginal photocurrent of the electrode was evaluated to be ~12.6 mA cm⁻² under simulated sunlight (AM 1.5 G, 1 sun) (Fig. S5†). The influence of necking treatment to the Ta₃N₅ particles were further ascertained by photocatalytic O₂ evolution. In a PC reaction (Fig. 4a), light is harvested in the Ta₃N₅ crystal and photogenerated charges drift to the active sites to take part in the surface reaction. The proportion of photogenerated charges that reach the surface reaction sites to those generated in Ta₃N₅ particles upon illumination is

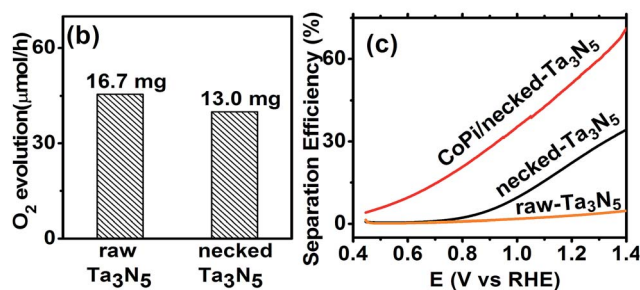
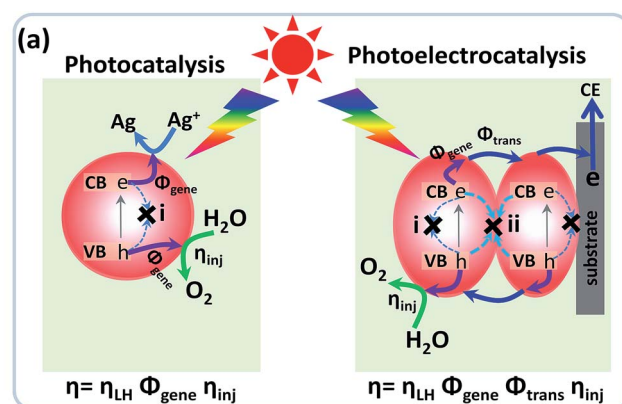


Fig. 4 (a) Schematic comparison of O₂ evolution processes *via* photocatalysis (AgNO₃ as electron scavenger) and photoelectrocatalysis. (b) Photocatalytic activity of the Ta₃N₅ powder peeled from raw-Ta₃N₅ and necked-Ta₃N₅ electrodes. The mass of the photocatalyst is listed above the column, respectively. (c) Charge separation efficiency of raw-Ta₃N₅ (orange), necked-Ta₃N₅ (black) and CoPi/necked-Ta₃N₅ electrodes (red).

referred as charge generation efficiency (Φ_{gene}), which is basically the charge separation efficiency in the Ta_3N_5 crystal. To preventing possible confusion with the separation efficiency in the electrode (as will be mentioned below), we define it as generation efficiency for the crystal. This generation efficiency is largely determined by the bulk property of the crystal. The proportion of photogenerated holes that take part in the (electro)chemical reaction to those arriving at the reaction sites is referred as injection efficiency (η_{inj}), which is influenced by the surface property of Ta_3N_5 . When the surface is not preferred for catalytic water oxidation, although sufficient holes reach the reaction sites, they cannot be consumed in time and η_{inj} will be less than unity. In the presence of efficient electron scavengers, the influence of electrons in the crystal is limited and the PC reaction can be used to evaluate the intrinsic properties of the Ta_3N_5 particles, such as the charge generation in the crystals and hole injection on the surfaces.⁴² The PC activities of the Ta_3N_5 powder from the raw- Ta_3N_5 electrode and necked- Ta_3N_5 electrode were evaluated with AgNO_3 as sacrificial reagent.²⁶ As is shown in Fig. 4b, the amount of released O_2 for necked- Ta_3N_5 has slightly decreased, implying that necking treatment has limited influence on the intrinsic property of Ta_3N_5 .

Then we focussed on the impact of necking treatment to the electron transfer at the PP and PS interfaces in the Ta_3N_5 electrode. In a PEC reaction (Fig. 4a), electrons and holes should be considered simultaneously since the electrons need to transfer through the Ta_3N_5 films during the PEC water oxidation. The transportation of photogenerated charges will be another factor that limits the PEC performance.

As it is reported, the final photocurrent is determined by the following expression:^{43,44}

$$J = J_0 \eta_{\text{LH}} \eta_{\text{sep}} \eta_{\text{inj}} \quad (2)$$

where J_0 is the theoretical photocurrent, η_{LH} is the light harvest efficiency, η_{inj} is the charge injection efficiency as defined above, and η_{sep} is separation efficiency in the electrode as defined in ref. 43.

The absorption and PC water oxidation measurement have revealed that necking treatment has little influence on light harvest (η_{LH}) and surface reaction (η_{inj}). Hence, the difference of charge separation (η_{sep}) of the electrode should be responsible for the huge difference of the PEC activity. Taking H_2O_2 as hole scavenger,⁴³ the charge separation efficiency is calculated. From Fig. 4c, it is revealed that the charge separation in raw- Ta_3N_5 electrode is inefficient, but necking treatment improves η_{sep} to more than 30% at the bias of 1.3 V vs. RHE. Interestingly, we found that CoPi/necked- Ta_3N_5 electrode has an even higher η_{sep} of 60% at 1.3 V vs. RHE.

A higher separation efficiency means less electron-hole recombination in the electrode. For a photoelectrocatalytic reaction occurring on a particulate electrode (Fig. 4a), the recombination may occur *via* two routes: (i) recombination in the particles through, for example, bulk defects or surface states; (ii) recombination at the interfaces of particles. Thus the measured separation efficiency should be dependent on the

charge generation in particles and transfer among particles under illumination:

$$\eta_{\text{sep}} = \Phi_{\text{gene}} \Phi_{\text{trans}} \quad (3)$$

where Φ_{gene} is the charge generation efficiency as mentioned in Ta_3N_5 crystal, relating to recombination process (i), and Φ_{trans} is the transportation efficiency for photogenerated charges transferring through PP and PS interfaces before arriving at the conductive substrate from the origin,⁴⁵ relating to recombination process (ii).

CoPi has been reported to suppress the surface states, and more long-lived photogenerated holes can survive in the particles.⁴⁶ Thus, the Φ_{gene} is increased and this leads to the cocatalyst promoted charge separation for the CoPi/necked- Ta_3N_5 electrode (Fig. 4c). For the necked- Ta_3N_5 electrode, the previous absorption (Fig. S5†) and PC activity (Fig. 4b) indicates a similar Φ_{gene} . Thus, the dramatically improved η_{sep} for necked- Ta_3N_5 electrode should stem from the improved Φ_{trans} upon necking treatment.

To consolidate the conclusion, prototypical devices fabricated from Ta_3N_5 electrodes (Fig. 5a, see ESI for details†) were used to delve into the charge transportation in the electrode by TPV. In Fig. 5b, the necked- Ta_3N_5 based device shows higher transient photovoltage and faster decay process than the raw- Ta_3N_5 based device. A linear response of current-bias (Fig. S6†) confirms the ohmic contact at the interfaces of PS.²⁰ Thus, the detected photovoltage plausibly stems from the Dember effect and this was further confirmed by the relationship between the direction of the induced laser and electric field. For the Dember effect, holes always stay closer to the top layer, and the direction of the electric field is always consistent with the direction of the laser beam (Fig. S7a†), and the intensity of the Dember voltage is determined by the amount of separated charges. Light of stronger intensity will induce more separated charges and hence a higher photovoltage (Fig. S7b†). When the intensity of the induced light is the same, and the same amount of charges are generated, a higher photovoltage indicates better charge separation. Thus the higher photovoltage of the necked- Ta_3N_5 device indicates that it shows better charge separation which is in accordance with the result in Fig. 4.

When light is removed, the electron-hole pairs will recombine, leading to a dynamic decay of the Dember photovoltage at the time scale of μs (Fig. 5b, solid line). Two plausible recombination processes mentioned above are involved in the decay process. Dual exponential curves (Fig. 5b, dashed line) are fitted with a fast decay process (recombination in Ta_3N_5 crystals, lifetime of τ_1) and a slow one (recombination at interfaces, lifetime of τ_2). The two electrodes have approximately the same τ_1 values, confirming again that the Ta_3N_5 particles on both electrodes have similar charge generation efficiency (Φ_{gene}) as the PC result reveals in Fig. 4a. However, the necked- Ta_3N_5 electrode has lower τ_2 , indicating that the electron-hole pairs more readily recombine through the interfaces in the TPV devices.

In order to clarify the result of TPV further, an equivalent circuit (EC) based on the transmission line model⁴⁷ (Fig. 5c) was



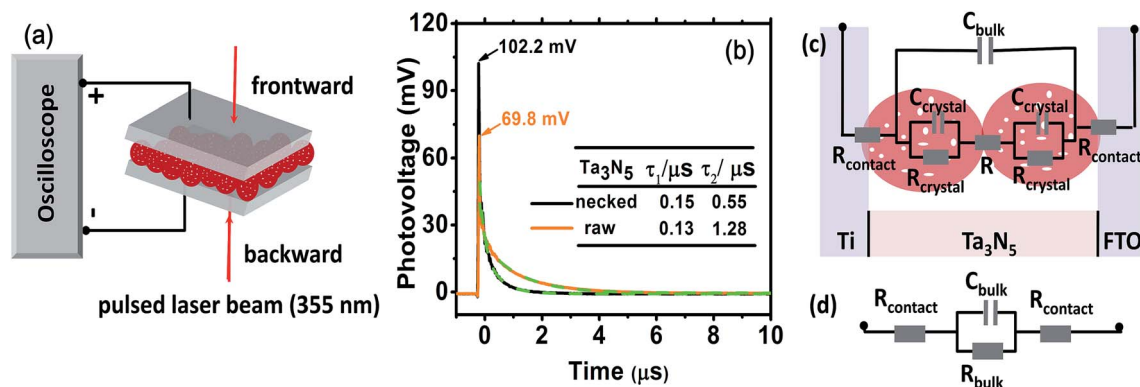


Fig. 5 (a) Schematic setup for TPV test. (b) TPV spectra of raw-Ta₃N₅ (orange) and necked-Ta₃N₅ electrode (black) with dual exponential fitted curves (green dashed curves). The inset table shows the lifetimes of the two electrodes, respectively. (c) Equivalent circuit of the device. (d) The simplified circuit of (c). R_{contact} is the serial resistance at the particle–substrate interfaces; R_{bulk} is the total resistance in Ta₃N₅ films including the resistance in Ta₃N₅ particles (R_{crystal}) and at particle–particle interfaces (R); C_{bulk} is the capacity of the parallel-plate capacitor built by Ti and FTO.

used to simulate the decay process in the device. Because there is no semiconductor/electrolyte interface, only three processes are considered: (i) the electron transport resistance in the Ta₃N₅ crystals (R_{crystal}), (ii) the electron transport resistance among particles (R) and particles–substrate (R_{contact}), (iii) a capacitive charging to the porous Ta₃N₅ matrix (C_{bulk}). For the Ta₃N₅ crystal, the conduction band or the defect energy level can accommodate electrons which can behave like a capacitor (C_{crystal}). C_{bulk} can be estimated to be at the order of 10^{-5} F cm⁻², while C_{crystal} is around 10^{-8} F cm⁻² (see ESI† for details†). Thus, C_{crystal} is much smaller compared to C_{bulk} and the series of C_{crystal} make it even smaller, so that we can ignore C_{crystal} . So the equivalent circuit in Fig. 5c can be reduced to that in Fig. 5d, including the resistance among and in Ta₃N₅ particles. The time constant ($\tau' = R_{\text{bulk}}C_{\text{bulk}}$) of electronic decay in the simulated circuit corresponds to the lifetime (τ) determined by TPV. As the bulk capacitance (C_{bulk}) of the two devices (raw-Ta₃N₅ and necked-Ta₃N₅) are estimated to be of the same order of magnitude based on eqn (S1) (ESI†) the change in time constant is reflected in the change of resistance in the device. Comparing the lifetime of τ_2 in the two types of Ta₃N₅ electrodes as tabulated in Fig. 5b, the smaller τ_2 of the necked-Ta₃N₅ electrode means that necking treatment decreases the charge transfer resistance (R_{bulk}) in the Ta₃N₅ film.

The amorphous layer of nitrogen doped tantalum oxide that bridges the Ta₃N₅ particles is a plausible route for electron transportation. As necking treatment is performed at high temperature, efficient connection at interfaces of PP will be formed. Additionally, nitrogen doping in the tantalum oxide layer can improve its conductivity⁴⁸ and facilitate the transportation of the photogenerated charges. Indeed, it is reasonable that low charge transfer resistance should lead to the high photovoltage and fast decay process since the Dember photovoltage is caused by drifting apart of electron–hole pairs, the better the conductivity is, the easier they can be dissociated/recombined, and *vice versa*.

The efficiency of electron transportation across the interfaces of PP and PS was further probed using the benchmark

redox couple of ferri/ferrocyanide.²³ The exchange of electrons between the solution and electrodes is fast (Fig. S8(a)†), allowing for the characterization of electron transfer by CV. The reduction reaction occurring on the Ta₃N₅ electrode (without illumination) can provide a direct measure on the electron transportation. In darkness, the electrochemical reduction occurs by transferring electrons from the Ta₃N₅ electrode to K₃Fe(CN)₆. Better electron transportation in the film will lead to more facial electron exchange. Moreover, the improved electron transfer in the film will decrease the ohmic polarization of the electrode and decrease the overpotential for the reduction of K₃Fe(CN)₆. The CV reveals that Ta₃N₅ is poor for hydrogen evolution (Fig. S8(b)†) but active for K₃Fe(CN)₆ reduction (Fig. S8(c)†). This allows us to focus on the electron exchange between the electrode and K₃Fe(CN)₆ regardless of the influence of hydrogen evolution in the potential window of -0.4 to 1.2 V *vs.* RHE. Fig. S8(c)† shows that the reduction peak of K₃Fe(CN)₆ shifts positively on Ta₃N₅ electrode, indicating that Ta₃N₅ is superior to Ti substrate in electrocatalytic reduction of K₃Fe(CN)₆. When Ta₃N₅ film has a good contact with the substrate, more electrons will be exchanged with K₃Fe(CN)₆ on the Ta₃N₅ particles than on the Ti substrate (Fig. S9†). Thus, the results in Fig. 6a can be related to electron transfer in the Ta₃N₅ film. It is found that the necked-Ta₃N₅ electrode has a reduction current of -19.7 mA cm⁻² at 0.65 V *vs.* RHE, while that for the raw-Ta₃N₅ electrode is -18.1 mA cm⁻² at 0.38 V *vs.* RHE, which is similar to that of the substrate (Fig. S8(c)†). The more positive potential along with higher current of the reduction peak indicates more efficient electron exchange on necked-Ta₃N₅ electrode. Because electrons should transport through the particulate Ta₃N₅ film, it is concluded that necked-Ta₃N₅ electrode is superior to raw-Ta₃N₅ electrode in electron transportation (Fig. S9†). The reduction peak potential of raw-Ta₃N₅ electrode (0.38 V *vs.* RHE) is close to the substrate (0.37 V *vs.* RHE), indicating that more electrons are leaked out through the substrate other than through Ta₃N₅ because of the weak connection at the PS interfaces. Additionally, the CV of CoPi/necked-Ta₃N₅ electrode is similar to that of necked-Ta₃N₅



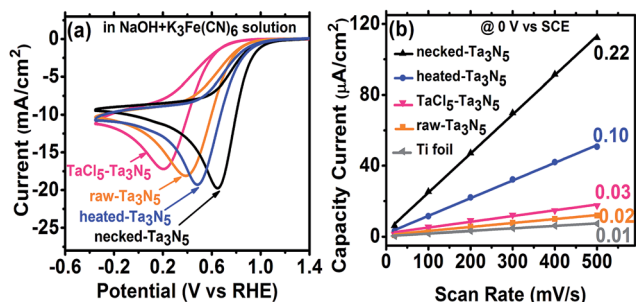


Fig. 6 (a) Cyclic voltammograms on raw-Ta₃N₅ (orange), TaCl₅-Ta₃N₅ (pink), heated-Ta₃N₅ (blue) and necked-Ta₃N₅ (black) electrodes for the reduction of ferricyanide in NaOH + K₃Fe(CN)₆ aqueous solution. (b) The plots of capacitive current to scan rate for the Ti foil (grey), raw-Ta₃N₅ (orange), TaCl₅-Ta₃N₅ (pink), heated-Ta₃N₅ (blue) and necked-Ta₃N₅ (black) electrodes. The slopes are shown beside the curves.

electrode (Fig. S8(d)†), confirming that CoPi has little impact on the charge transfer in the electrode.

To sum up, necking treatment can facilitate charge transfer at the PP and PS interfaces in the Ta₃N₅ film which is beneficial for the collection of photogenerated electrons, and depressing the recombination at the interfaces.

For particulate electrode, only the particles having good connection with the conductive layer can provide the area for electrochemical reaction. If an electrode made from powder has good conductivity in the film a porous structure with large electrochemical active area is expected. By eliminating the influence of the diffusion layer with concentrated electrolyte, we can get the relative area of the electrode from its charging capacitance of the Helmholtz double layer based on the following expression:^{8,24}

$$j = \nu C = (\epsilon S / 4\pi d) \nu \quad (4)$$

where ν is the scan rate, and C is the capacitance of the double layer which is proportional to the surface area S .

Here, we measured the charging current (j) in a potential window (-0.1 to 0.2 V vs. SCE) where there is no faradaic current

at different scan rates without illumination (Fig. S10†). The j - ν plot of each electrode is shown in Fig. 6b and the slope should be proportional to the surface area based on eqn (4). Taking the area of bare Ti substrate as unit, it is found the area only increases a little with TaCl₅ treatment or heating. However, the refined necking treatment leads to 22 times larger electrochemical surface area. Based on the analysis above, it is inferred that for raw-Ta₃N₅ electrode, the poor connection in the particulate Ta₃N₅ layer contributes little to the electrochemical active area. Only the layer of Ta₃N₅ contact with the substrate can be used for reaction (Fig. S9,† left) and thus the electrochemical area is limited. After necking treatment, the connection at the interfaces of particle-particle (PP) and particle-substrate (PS) are improved substantially and even the layer of Ta₃N₅ far from the substrate can be used for reaction (Fig. S9,† right). Thus the necked-Ta₃N₅ electrode provides a much larger electrochemical surface area for reaction.

Inspired by the results above, another example was further raised to support the conclusion. We found that the necking treatment can improve the photocurrent to 6.0 mA cm^{-2} at 1.6 V vs. RHE for the Ta₃N₅ electrodes made from traditional thermal oxidation-nitridation method (Fig. S11, see ESI for details†).

As for the role of CoPi, it can improve the charge separation by enhancing the charge generation in the Ta₃N₅ crystal as shown above. Further, the surface charge injection process is also greatly accelerated with CoPi (Fig. S12†). Because of the cocatalyst promoted charge separation and injection, the CoPi/necked-Ta₃N₅ electrode can provide a photocurrent of 11.2 mA cm^{-2} at 1.6 V vs. RHE . Moreover, the fast consuming of photogenerated holes can protect Ta₃N₅ from being oxidized.⁴⁴ Thus, the stability of the necked-Ta₃N₅ electrode is substantially improved with the assistance of CoPi as shown in Fig. 7a. The near unit faradaic efficiency of the CoPi/necked-Ta₃N₅ electrode (Fig. 7b) confirms that the photocurrent is originated from O₂ evolution reaction. However, the photocurrent decayed noticeably with prolonged time (Fig. 7a). The failure of the Ta₃N₅ electrode is suspected to be the result of the large surface area of the particulate electrode which makes it difficult to wholly cover Ta₃N₅ with effective co-catalyst in the porous structure. Many unconsumed photogenerated holes were accumulated and destroyed the intrinsic Ta₃N₅. Further efforts to improve the stability is still in progress.

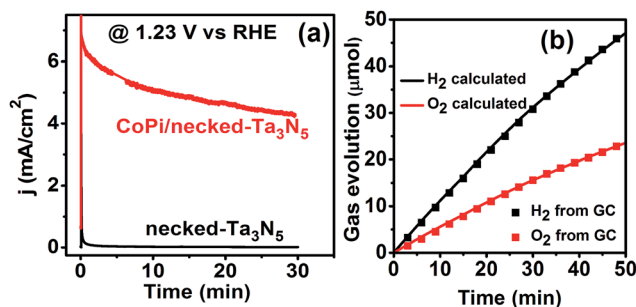


Fig. 7 (a) Stability of the necked-Ta₃N₅ (black) and CoPi/necked-Ta₃N₅ (red) photoanodes at 1.23 V vs. RHE . (b) Faradaic efficiency of the CoPi/necked-Ta₃N₅ photoanode at 1.23 V vs. RHE . Electrolyte: 1 M NaOH aqueous solution. Illumination: 100 mW cm^{-2} , Xe lamp (wavelength $> 420 \text{ nm}$), area: 0.6 cm^2 .

Conclusions

Efficient Ta₃N₅ photoanode is fabricated on Ti foil by EPD method with refined necking treatment. Further loading cocatalyst CoPi gives a photocurrent of 6.1 mA cm^{-2} at 1.23 V vs. RHE under simulated sunlight (AM 1.5 G). To the best of our knowledge, this is the highest photoresponse for an electrode made by EPD. The benefit of necking treatment is proved to stem from the high-temperature treatment and the formation of a nitrogen-doped tantalum oxide layer, which can improve the charge separation efficiency. The TPV shows higher open-circuit voltage and faster decay process for necked-Ta₃N₅ electrode, which suggests that necking treatment can decrease the charge transfer resistance at particle-particle interfaces. This



will promote the collection of photogenerated charges, decrease the recombination at the interfaces and improve the charge separation efficiency. CV measurement further confirms the benefit of necking treatment in promoting electron transfer and providing higher electrochemically active area for surface water oxidation.

Acknowledgements

This work was supported by the Basic Research Program of China (973 Program: 2014CB239403), and Natural Science Foundation of China (No. 21522306, 21373210).

Notes and references

- 1 N. Getoff, *Int. J. Hydrogen Energy*, 1990, **15**, 407–417.
- 2 X. Chen, S. Shen, L. Guo and S. S. Mao, *Chem. Rev.*, 2010, **110**, 6503–6570.
- 3 Z. Chen, T. F. Jaramillo, T. G. Deutsch, A. Kleiman-Shwarsstein, A. J. Forman, N. Gaillard, R. Garland, K. Takanabe, C. Heske and M. Sunkara, *J. Mater. Res.*, 2010, **25**, 3.
- 4 D. Kang, T. W. Kim, S. R. Kubota, A. C. Cardiel, H. G. Cha and K. S. Choi, *Chem. Rev.*, 2015, **115**, 12839–12887.
- 5 K. Maeda, T. Takata, M. Hara, N. Saito, Y. Inoue, H. Kobayashi and K. Domen, *J. Am. Chem. Soc.*, 2005, **127**, 8286–8287.
- 6 S. Chen, J. Yang, C. Ding, R. Li, S. Jing, D. Wang, H. Han, F. Zhang and C. Li, *J. Mater. Chem. A*, 2013, **1**, 5651–5659.
- 7 X. Wang, Q. Xu, M. Li, S. Shen, X. Wang, Y. Wang, Z. Feng, J. Shi, H. Han and C. Li, *Angew. Chem., Int. Ed.*, 2012, **51**, 13089–13092.
- 8 B. A. Pinaud, P. C. Vesborg and T. F. Jaramillo, *J. Phys. Chem. C*, 2012, **116**, 15918–15924.
- 9 Y. Ling, G. Wang, D. A. Wheeler, J. Z. Zhang and Y. Li, *Nano Lett.*, 2011, **11**, 2119–2125.
- 10 Z. Wang, G. Liu, C. Ding, Z. Chen, F. Zhang, J. Shi and C. Li, *J. Phys. Chem. C*, 2015, **119**, 19607–19612.
- 11 S. D. Tilley, M. Cornuz, K. Sivula and M. Grätzel, *Angew. Chem.*, 2010, **122**, 6549–6552.
- 12 L. Zhang, T. Minegishi, J. Kubota and K. Domen, *Phys. Chem. Chem. Phys.*, 2014, **16**, 6167–6174.
- 13 C. Zhen, T. Wu, M. W. Kadi, I. Ismail, G. Liu and H.-M. Cheng, *Chin. J. Catal.*, 2015, **36**, 2171–2177.
- 14 Y. Li, L. Zhang, A. Torres-Pardo, J. M. González-Calbet, Y. Ma, P. Oleynikov, O. Terasaki, S. Asahina, M. Shima and D. Cha, *Nat. Commun.*, 2013, **4**, 2566.
- 15 Y. Qiu, S.-F. Leung, Q. Zhang, B. Hua, Q. Lin, Z. Wei, K.-H. Tsui, Y. Zhang, S. Yang and Z. Fan, *Nano Lett.*, 2014, **14**, 2123–2129.
- 16 M. Stefik, M. Cornuz, N. Mathews, T. Hisatomi, S. Mhaisalkar and M. Grätzel, *Nano Lett.*, 2012, **12**, 5431–5435.
- 17 S. R. Pendlebury, M. Barroso, A. J. Cowan, K. Sivula, J. Tang, M. Grätzel, D. Klug and J. R. Durrant, *Chem. Commun.*, 2011, **47**, 716–718.
- 18 Y. Tamaki, A. Furube, M. Murai, K. Hara, R. Katoh and M. Tachiya, *Phys. Chem. Chem. Phys.*, 2007, **9**, 1453–1460.
- 19 Y. Ma, S. R. Pendlebury, A. Reynal, F. Le Formal and J. R. Durrant, *Chem. Sci.*, 2014, **5**, 2964–2973.
- 20 R. Esposito, J. Loferski and H. Flicker, *J. Appl. Phys.*, 1967, **38**, 825–831.
- 21 R. Wilson, *Crit. Rev. Solid State Mater. Sci.*, 1980, **10**, 1–41.
- 22 L. M. Peter, *Chem. Rev.*, 1990, **90**, 753–769.
- 23 Y. W. Chen, J. D. Prange, S. Dühnen, Y. Park, M. Gunji, C. E. Chidsey and P. C. McIntyre, *Nat. Mater.*, 2011, **10**, 539–544.
- 24 A. J. Bard and L. R. Faulkner, *Electrochemical methods: fundamentals and applications*, Wiley, New York, 1980.
- 25 M. de Respinis, M. Fravventura, F. F. Abdi, H. Schreuders, T. J. Savenije, W. A. Smith, B. Dam and R. van de Krol, *Chem. Mater.*, 2015, **27**, 7091–7099.
- 26 S. Chen, S. Shen, G. Liu, Y. Qi, F. Zhang and C. Li, *Angew. Chem., Int. Ed.*, 2015, **54**, 3047–3051.
- 27 P. Zhang, J. Zhang and J. Gong, *Chem. Soc. Rev.*, 2014, **43**, 4395–4422.
- 28 X. Zong, S. Thaweesak, H. Xu, Z. Xing, J. Zou, G. M. Lu and L. Wang, *Phys. Chem. Chem. Phys.*, 2013, **15**, 12314–12321.
- 29 D. Wang, R. Li, J. Zhu, J. Shi, J. Han, X. Zong and C. Li, *J. Phys. Chem. C*, 2012, **116**, 5082–5089.
- 30 M. Liao, J. Feng, W. Luo, Z. Wang, J. Zhang, Z. Li, T. Yu and Z. Zou, *Adv. Funct. Mater.*, 2012, **22**, 3066–3074.
- 31 R. Abe, M. Higashi and K. Domen, *J. Am. Chem. Soc.*, 2010, **132**, 11828–11829.
- 32 M. Higashi, K. Domen and R. Abe, *J. Am. Chem. Soc.*, 2012, **134**, 6968–6971.
- 33 S. S. Gujral, A. N. Simonov, X.-Y. Fang, M. Higashi, T. Gengenbach, R. Abe and L. Spiccia, *Catal. Sci. Technol.*, 2016, DOI: 10.1039/C5CY01432H.
- 34 M. Higashi, K. Domen and R. Abe, *J. Am. Chem. Soc.*, 2013, **135**, 10238–10241.
- 35 M. Hara, E. Chiba, A. Ishikawa, T. Takata, J. N. Kondo and K. Domen, *J. Phys. Chem. B*, 2003, **107**, 13441–13445.
- 36 A. Arranz and C. Palacio, *Appl. Phys. A: Mater. Sci. Process.*, 2005, **81**, 1405–1410.
- 37 D. Yokoyama, H. Hashiguchi, K. Maeda, T. Minegishi, T. Takata, R. Abe, J. Kubota and K. Domen, *Thin Solid Films*, 2011, **519**, 2087–2092.
- 38 A. Ibidunni, R. MaSaitis, R. Opila, A. Davenport, H. Isaacs and J. Taylor, *Surf. Interface Anal.*, 1993, **20**, 559–564.
- 39 M. W. Kanan, Y. Surendranath and D. G. Nocera, *Chem. Soc. Rev.*, 2009, **38**, 109–114.
- 40 M. Higashi, K. Domen and R. Abe, *Energy Environ. Sci.*, 2011, **4**, 4138–4147.
- 41 J. Feng, W. Luo, T. Fang, H. Lv, Z. Wang, J. Gao, W. Liu, T. Yu, Z. Li and Z. Zou, *Adv. Funct. Mater.*, 2014, **24**, 3535–3542.
- 42 J. Yang, D. Wang, H. Han and C. Li, *Acc. Chem. Res.*, 2013, **46**, 1900–1909.
- 43 H. Dotan, K. Sivula, M. Grätzel, A. Rothschild and S. C. Warren, *Energy Environ. Sci.*, 2011, **4**, 958–964.
- 44 G. Liu, J. Shi, F. Zhang, Z. Chen, J. Han, C. Ding, S. Chen, Z. Wang, H. Han and C. Li, *Angew. Chem., Int. Ed.*, 2014, **53**, 7295–7299.



- 45 B. C. O'Regan, K. Bakker, J. Kroeze, H. Smit, P. Sommeling and J. R. Durrant, *J. Phys. Chem. B*, 2006, **110**, 17155–17160.
- 46 M. Barroso, A. J. Cowan, S. R. Pendlebury, M. Grätzel, D. R. Klug and J. R. Durrant, *J. Am. Chem. Soc.*, 2011, **133**, 14868–14871.
- 47 F. Fabregat-Santiago, G. Garcia-Belmonte, J. Bisquert, A. Zaban and P. Salvador, *J. Phys. Chem. B*, 2002, **106**, 334–339.
- 48 H. Nie, S. Xu, S. Wang, L. You, Z. Yang, C. Ong, J. Li and T. Liew, *Appl. Phys. A: Mater. Sci. Process.*, 2001, **73**, 229–236.

